

UCLA CNSI Electron-Beam System Job Submission Form

Contact Information

Job# (for staff)	Date	User Name and Group Affiliation	Budge#	Recharge ID	Phone and/or Email

Pattern Information

File Name (GDS)	Critical (nm) Dimensions	Resolution (nm) / Beam-Step-Size	Pattern Size:
File name (GPF, for staff)			X: Y:

E-beam Settings and Resist information

Beam Current (nA)	Dose ($\mu\text{C}/\text{cm}^2$)	If Dose Test,Dose Step ($\mu\text{C}/\text{cm}^2$)	Resist Type, Thickness and Spin Rate

Layout Step, Repeat and Sample Information

Number of Cells in X	Number of Cells in Y	Pitch in X (μm)	Pitch in Y (μm)	Layout Type	Sample Size and Sample Materials (4", 2" or piece(x,y))
				Retangle Circle	

Alignment Information --only needed if Alignment

Marker Shape (circle one)	Marker Material	Global Marker Pitch (μm)	Four Global Marker Coordinate (Suppose layout center is 0,0) Lower Left Corner(LLC) (LRC) (ULC) (URC)			
Retangle or Cross		X: Y:				
Marker Size	Marker Type	Local Marker Pitch (μm)	Four Local Marker Coordinate (Suppose pattern center is 0,0) Lower Left Corner(LLC) (LRC) (ULC) (URC)			
	(P)ositive (N)egative	X: Y:				

Finance Charges Information

Machine Time Spent	Staff Time Spent	Additional Charges (A)	Signature
Machine Time Charged (M)	Staff Time Charged (S)	Total Amount (M+S+A)	Date:

Comments